

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:  
Garry A. Mercaldi, et al.

Application No.: 09/285,773

Filed: April 5, 1999

For: METHOD FOR ETCHING DOPED  
POLYSILICON WITH HIGH  
SELECTIVITY TO UNDOPED  
POLYSILICON



Group Art Unit: 1765

Examiner: L. Eronini

AMENDMENT UNDER 37 CFR 1.116

Box AF

Assistant Commissioner for Patents  
Washington, DC 20231

Dear Sir:

In response to the Office Action dated October 23, 2000 (Paper No. 9), finally rejecting claims 1-7, 9-11, 13-18, 22-41 and 82-86, please amend the above-identified U.S. Patent application as follows:

IN THE CLAIMS:

Please amend the following claims:

1. (Twice Amended) A composition for selectively etching a doped substance,  
said composition consisting essentially of:

a non-aqueous composition of an alcohol and at least two inorganic acids[,  
wherein a major component of said composition is non-aqueous].